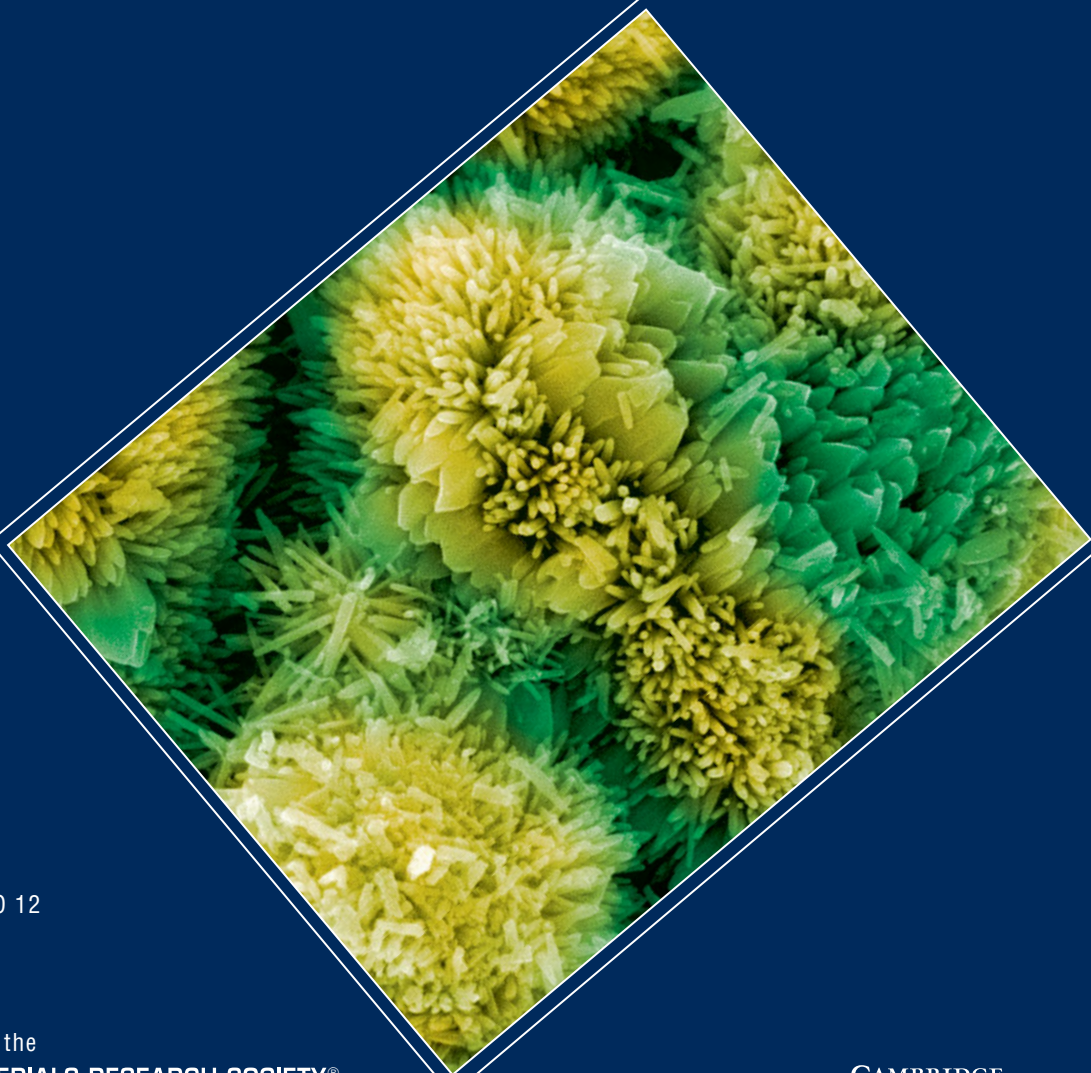


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VOLUME 30 • NO 12  
JUNE 28, 2015

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Cover: FIG. 3(b). SEM images of sample as-obtained ZnO; (C-G) Ni-decorated ZnO with Ni loadings of 2.0%, 4.5%, 9.0%, 13.0% and 17.5%, respectively. [G. Yang, Q. Liu, Y. Fu, H. Ma, C. Ma, X. Dong, X. Zhang, X. Zhang: Improved Photocatalytic reactivity of ZnO photocatalysts decorated with Ni and their magnetic recoverability. p. 1902].

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